SYNTHESIS OF [2.2]CYCLOPHANES BY PHOTODESELENATIVE RINGCONTRACTION<sup>1)</sup>

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<u>Summary</u>: Several cyclophanes were prepared by photodeselenation of diselena[3.3]cyclophanes with hexamethylphosphorous triamide in excellent yields, compared with the other chalcogen-atom extrusion methods.

In the preceding paper of this series, we reported the synthesis of diselena[3.3]cyclophanes by a reductive coupling of bisselenocyanates with dihalides and the following deselenation using Stevens rearrangement-hydrogenolysis or flash pyrolysis to give {2.2]cyclophanes.<sup>1)</sup> We wish to report a more facile, general synthesis of [2.2]cyclophane system by photodeselenative ringcontraction of the diselenacyclophanes, compared with the two deselenation methods abovestated.



Among a variety of phosphorus reagents, hexamethylphosphorous triamide,  $P(NMe_2)_3$ , was found to be a good reagent for the photodeselenation reaction just as trialkyl phosphite for the photodesulfurization<sup>2)</sup> of dithiacyclophanes. On irradiation of a solution of diselenacyclophane (50 mg) and excess hexamethylphosphorous triamide (ca. 1 g) in THF (30-50 ml) with a 400W high pressure mercury lamp under nitrogen bubbling, the desired cyclophanes shown in Table were easily separated by the usual work-up. The structures of the cyclophanes were identified by comparison of PMR, MS, and other spectra with the authentic samples.

The table shows that the yields of cyclophanes 1 - 6 by the photodeselenation are much higher than those by both Stevens rearrangement-hydrogenolysis

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Yields of [2.2]Cyclophanes and Irradiation Times Table. 3)5) 4) 5) 4) 6) Product 3 1 2 4 5 6 a) 53 <sup>c)</sup> Yield(%) 93 48 80 51 25 **b**) hv(hr)4.5 20 16 23 47 22

\* New C-C bonds by photodeselenation. a) Isolated yields. b) Irradiation time.
c) A by-product, monoselenacyclophane of 14% yield.

and flash pyrolysis of diselenacyclophanes,<sup>1)</sup> the photodesulfurization of the corresponding dithiacyclophanes,<sup>3,4)</sup> and thermal desulfonation of cyclic disulfones.<sup>5)</sup> Consequently it should be emphasized that the present method is obviously preferred over all of chalcogen-atom extrusion methods so far studied for [2.2]cyclophane synthesis, since the intermediate diselena[3.3]cyclophanes are easily prepared in fairly good yields.

## References

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